

PLC BASED FLEXIBLE AND SCALABLE VACUUM CONTROL AT THE ARGONNE TANDEM LINEAR ACCELERATOR SYSTEM (ATLAS)*

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Abstract

The beamline sections of an accelerator and different ion sources require a vacuum system capable of providing pressures down to 10^{-10} Torr. To control, monitor, and provide interlock protection of the vacuum equipment, a PLC-based vacuum control system was developed and tested at the Argonne Tandem Linear Accelerator (ATLAS). This system was designed to be highly flexible and scalable to meet the variety of equipment and configurations at ATLAS. The current FPGA-based system is reliable and fast, but is very difficult to maintain and upgrade. Particular attention was paid to the signal distribution to promote standard cable connections, minimize the usage of terminal blocks, and reduce the time to troubleshoot problematic channels. The system monitors the status of fast acting relays for interlock or control purposes, and utilizes RS-485 communication to gather lower priority information such as pump speeds or vacuum pressure readouts. The vacuum levels are monitored to interlock the high voltages of some beam instruments to protect against sparks as the Paschen minimum is approached. This paper mainly presents work on hardware interface to various vacuum devices.

INTRODUCTION

ECR (Electron Cyclotron Resonance) and EBIS (Electron Beam Ion Source) ion sources are used at ATLAS to generate beams along with other sources. There are two ECR (ECR2 and ECR3) sources and one EBIS here.

Paschen's law is an equation that describes the breakdown voltage between two electrodes in a gas as a function of pressure and gap length [1]. As shown in Fig. 1, the breakdown voltage drops dramatically when the vacuum condition of the system gets worse from high vacuum level. Without any protection, some beam instruments such as beam extractor, puller may generate high voltage (HV) sparks which could damage themselves or other beam components. So it is very important to interlock the HV bias of those beam instruments to the related vacuum levels to prevent HV sparks related to bad vacuum.

We have some aged in-house custom built vacuum hardware used for some other beam sections. It combined analog logic control circuitry and outdated FPGA (Field Programmable Gate Array) devices to control some specific vacuum devices. There are different revisions depending on their original intended purposes. For example, some chassis don't provide a remote vacuum pressure reading and some don't support a separate turbo pump, causing additional effort to integrate into the control system [2].

A new PLC (Programmable Logic Controller) based vacuum control system was proposed after communication with operators, engineers and management people. Then it was developed. The prototypes which were developed before finalized design requirement due to project schedule have been utilized in EBIS and ECR3. ECR3 is a newly developed ion source. The modified final design has been finished and will be deployed into other areas of ATLAS. The new system is highly flexible and scalable. The details are discussed below.

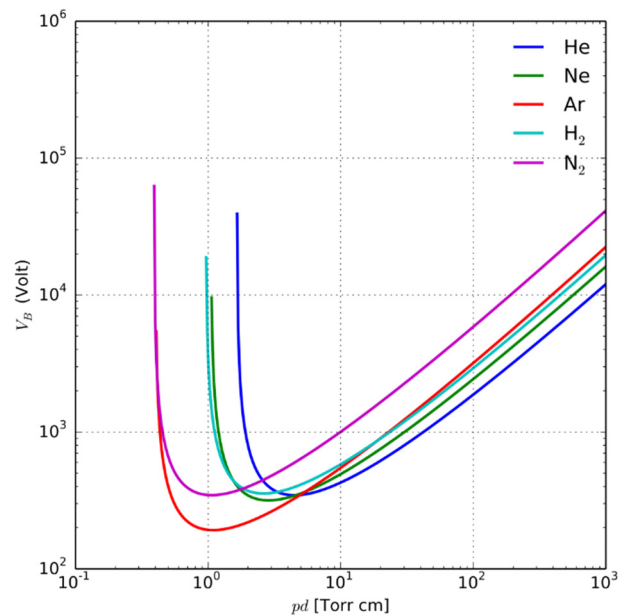


Figure 1: Paschen curves obtained for different gases.

DESIGN AND IMPLEMENTATION

The conceptual structure of the PLC based system is shown in Fig. 2. The PLC system used contains Modicon M340 system with Ethernet, RS-485 and some I/O modules, such as BMXDDI6402K and BMXDDO3202K. The PLC system communicates with the PLC interface, distributing output control and grouping input status signals. The interface chassis also provides RS-485 path for the PLC to collect pressure readout and other information. Then the valve and pump stations connect to the individual vacuum devices for controlling, status information collecting and RS-485 communication. Standard D-sub cables are used as much as possible to reduce the label time of making custom cables and costs. Most of the cables to the specific vacuum devices are also standard D-sub cables with one end re-terminated to the device's configuration.

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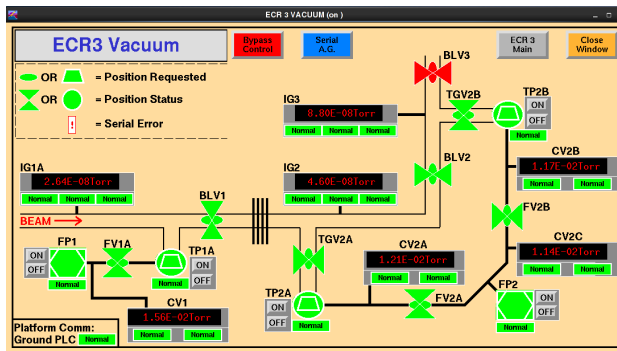


Figure 6: ECR3 PLC vacuum control system GUI.

CONCLUSION

The work of developing a PLC based vacuum control system for the beam devices and beam line have been conducted at ATLAS, the prototype system serves well for vacuum control and is providing vacuum level related HV interlock protection to the critical beam devices. Some finalized products are also built and ready to be deployed to other areas.

REFERENCES

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